

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of)	Attorney Docket No.: SOEI0021
)	
Ken SAWABE et al.)	Confirmation No. 9014
)	
Serial No.: 10/595,920)	Group Art Unit: 1795
)	
Filed: May 19, 2006)	Examiner: Amanda C. WALKE
)	
For: PHOTSENSITIVE RESIN)	Date: September 18, 2009
COMPOSITION, PHOTSENSITIVE)	
ELEMENT, RESIST PATTERN)	
FORMING METHOD AND PROCESS)	
FOR MANUFACTURING PRINTED)	
CIRCUIT BOARD)	

COMMENTS (G) ON STATEMENT OF REASONS FOR ALLOWANCE

MAIL STOP: ISSUE FEE

United States Patent and Trademark Office
Customer Service Window
Randolph Building
401 Dulany Street
Alexandria, VA 22314

Sir:

In response to the Notice of Allowance mailed June 19, 2009, please enter the following comments regarding the application identified above as follows:

Remarks/Arguments begin on page 2 of this paper.

REMARKS

In response to the Notice of Allowance mailed June 19, 2009, Applicants make the following Comments on Statement of Reasons for Allowance presented by the Examiner in the Office Action of June 19, 2009, at 2, lines 2-14. The Examiner's Reasons for Allowance deviates from the language of the allowed claims. Therefore, to the extent that the Examiner's Reasons for Allowance mischaracterize the allowed claims 1, 4-8, 11, 13, 15, 16, 18-20, 23, 25 and 26, Applicants object. The claims, as written, speak for themselves. Applicants agree that the claimed invention would not have been obvious at the time the invention was made, and that no prima facie showing of anticipation or obviousness could be made in view of the prior art of record.

Questions are welcomed by the below signed attorney for the Applicants.

Respectfully submitted,

GRIFFIN & SZIPL, P.C.



Joerg-Uwe Szimpl
Registration No. 31,799

Griffin & Szimpl, P.C.
Suite PH-1
2300 Ninth Street, South
Arlington, VA 22204

Telephone: (703) 979-5700
Facsimile: (703) 979-7429
Email: GandS@szimpl.com
Customer No.: 24203